L Number	Hits	Search Text	DB	Time stamp
1	249	renesas with technology	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 10:15
2	1	(renesas with technology) and (exposure with energy)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 10:18
3	3	(renesas with technology) and (exposure and energy)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 10:28
4	22684	exposure with energy	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 10:18
5	4743	(exposure with energy) and semiconductor and resist$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 10:19
6	4013	((exposure with energy) and semiconductor and resist$4) and substrate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 10:21
7	6	(((exposure with energy) and semiconductor and resist$4) and substrate) and (target adj dimension)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 10:21
8	1	(tokorozuki.in. with kazuyuki.in.) and (exposure and energy)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 10:29
9	1	(yokouchi.in. with tetsuji.in.) and (exposure and energy)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 10:30
10	3	(miyamoto.in. with yoshiyuki.in.) and (exposure and energy)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 10:30
11	4	(yamamoto.in. with koji.in.) and (exposure and energy)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 10:31
12	6	((tokorozuki.in. with kazuyuki.in.) and (exposure and energy)) or ((yokouchi.in. with tetsuji.in.) and (exposure and energy)) or ((miyamoto.in. with yoshiyuki.in.) and (exposure and energy)) or ((yamamoto.in. with koji.in.) and (exposure and energy))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 10:31